

AN EFFICIENT IMPLEMENTATION OF THE ACM **MOSFET MODEL IN ELDO FOR VLSI CIRCUIT** DESIGN

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Introduction

The ACM (Advanced Compact MOSFET) model is a chargebased physical model that consists of simple, accurate and single equations that represent the device behavior in all regimes of operation, using well-known physical parameters (http://eel.ufsc.br/~lci/acm/index.html).

Implementation

The ACM was implemented into the ELDO simulator using the UDM (User Definable Model) module. The model code was written in C. The iterative algorithm used for the numerical calculation of the inversion charge in the UCCM needs only one iteration to obtain relative errors of less than **10-7 in the whole inversion range.**

Parameters				
PARAMETERS	DESCRIPTION			
UO	Carrier mobility]		
ΤΟΧ	Gate oxide thickness			
VTO	Threshold voltage			
NA	Acceptor densities			
PHISO	Surface potential			
GAMMA	Body effect factor			
LAMBDA	Channel length modulation factor			
THETA	Mobility reduction factor			
Μ	Temperature factor			
VMAX	Velocity saturation			
XJ	Junction depth			
SIGMA	Drain-induced barrier lowering factor			



ab integer

TRAN

1s370ms

0.98

1.00

1.09





ferent models available in ELDO.					
	HiSIM	PSP	BSIM4		
	1.63	1.87	1.16		
	1.60	1.93	1.28		
	1.23	1.31	1.19		
	1.06	1.11	1.06		
	1.63	1.86	1.25		
	1.01	1.13	0.98		



Conclusions

The results show that ACM is a powerful and useful tool for simulation and design because it consists of simple, accurate and single equations together with a small number of physical parameters.

